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| APPLICATION NO.                                      | FILING DATE     | FIRST NAMED INVENTOR | ATTORNEY DOCKET NO. | CONFIRMATION NO. |
|--|-----------------|----------------------|---------------------|------------------|
| 10/629,678   | 07/30/2003      | Junji Kunisawa       | 2003_1074           | 6560             |
| 513  | 7590 03/29/2005 | EXAMINER             |                     | INER             |
| WENDEROTH, LIND & PONACK, L.L.P. 2033 K STREET N. W. |                 |                      | PERRIN, JOSEPH L    |                  |
| SUITE 800  | <i></i>         | 4                    | ART UNIT            | PAPER NUMBER .   |
| WASHINGTON, DC 20006-1021                            |                 |                      | 1746                |                  |

DATE MAILED: 03/29/2005

Please find below and/or attached an Office communication concerning this application or proceeding.

|  | Application No.  | Applicant(s)  |  |  |  |
|--|--|---|--|--|--|
| Office Action Summan   | 10/629,678   | KUNISAWA ET AL.   |  |  |  |
| Office Action Summary  | Examiner   | Art Unit  |  |  |  |
|  | Joseph L. Perrin, Ph.D.  | 1746  |  |  |  |
| The MAILING DATE of this communication app<br>Period for Reply   | pears on the cover sheet with the c  | correspondence address  |  |  |  |
| A SHORTENED STATUTORY PERIOD FOR REPL' THE MAILING DATE OF THIS COMMUNICATION.  - Extensions of time may be available under the provisions of 37 CFR 1.1 after SIX (6) MONTHS from the mailing date of this communication.  - If the period for reply specified above is less than thirty (30) days, a repl - If NO period for reply is specified above, the maximum statutory period of the period for reply within the set or extended period for reply will, by statute any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).          | 136(a). In no event, however, may a reply be tin<br>y within the statutory minimum of thirty (30) day<br>will apply and will expire SIX (6) MONTHS from<br>a, cause the application to become ABANDONE | nely filed  s will be considered timely. the mailing date of this communication. D (35 U.S.C. § 133). |  |  |  |
| Status   |  |   |  |  |  |
| 1)⊠ Responsive to communication(s) filed on <u>03 M</u>  | larch 2005.  |   |  |  |  |
|  | <u> </u>   |   |  |  |  |
| 3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is   |  |   |  |  |  |
| closed in accordance with the practice under Ex parte Quayle, 1935 C.D. 11, 453 O.G. 213.  |  |   |  |  |  |
| Disposition of Claims  |  |   |  |  |  |
| 4) ⊠ Claim(s) 1 & 5-8 is/are pending in the applicating 4a) Of the above claim(s) is/are withdraw 5) □ Claim(s) is/are allowed.  6) ⊠ Claim(s) 1 & 5-8 is/are rejected.  7) □ Claim(s) is/are objected to.  8) □ Claim(s) are subject to restriction and/or  | wn from consideration.   |   |  |  |  |
| Application Papers   |  |   |  |  |  |
| 9)☐ The specification is objected to by the Examine  | :r.  |   |  |  |  |
| 10)☐ The drawing(s) filed on is/are: a)☐ accepted or b)☐ objected to by the Examiner.  |  |   |  |  |  |
| Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).  |  |   |  |  |  |
| Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).  11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.   |  |   |  |  |  |
| Priority under 35 U.S.C. § 119   |  |   |  |  |  |
| <ul> <li>12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).</li> <li>a) All b) Some * c) None of:</li> <li>1. Certified copies of the priority documents have been received.</li> <li>2. Certified copies of the priority documents have been received in Application No.</li> <li>3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).</li> <li>* See the attached detailed Office action for a list of the certified copies not received.</li> </ul> |  |   |  |  |  |
|  | ·  |   |  |  |  |
| Attachment/e)  |  |   |  |  |  |
| Attachment(s)  1) Notice of References Cited (PTO-892)   | 4) Interview Summary   | (PTO_413)   |  |  |  |
| 2) Notice of Traftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) Paper No(s)/Mail Date   | Paper No(s)/Mail Da  |   |  |  |  |

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### **DETAILED ACTION**

## Response to Amendment

1. Upon further review and consideration of the parent application, the finality of the previous Office action is withdrawn in view of the previously cited reference(s) to U.S. Patent No. 5,534,073 to KINOSHITA *et al.* & U.S. Patent No. 6,164,133 to WATANABE. Rejections based on the newly cited reference(s) follow.

## Allowable Subject Matter

2. Upon further review and consideration of the parent application, the indicated allowable subject matter of claim 13 is withdrawn in view of the previously cited reference(s) to U.S. Patent No. 5,951,833 to YAMAGATA & U.S. Patent No. 5,534,073 to KINOSHITA *et al.* & U.S. Patent No. 6,164,133 to WATANABE. Rejections based on the newly cited reference(s) follow.

### Claim Rejections - 35 USC § 102

- 3. The text of those sections of Title 35, U.S. Code not included in this action can be found in a prior Office action.
- 4. Claims 1 & 5-7 are rejected under 35 U.S.C. 102(b) as being anticipated by U.S. Patent No. 5,951,833 to YAMAGATA. Re claim 1, YAMAGATA discloses a substrate holding unit with a holding plate (102) having an aperture (opening 103) and vacuum suction members (104) contacting only the outer periphery of the substrate (101), thereby defining "a space" sealed from one side of the substrate (see, for instance, col. 10, line 54 col. 11, line 30; Figure 1). Re claim 5, YAMAGATA further discloses the holding unit in combination with a surface processing unit (anodizing apparatus, see,

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col. 2, line 56 *et seq.*). Re claim 6, YAMAGATA further discloses using the holding unit and surface processing unit with a cleaning apparatus and/or a drying apparatus (see, col. 4, lines 1-6). Re claim 7, YAMAGATA further discloses using a dipping bath (see, col. 7, line 21, as well as Figure 1 and relative associated text). It is noted that applicant's recitation of purging gas is considered intended use and given little weight. That is, recitations that the space "can be purged by blowing N<sub>2</sub> gas thereinto..." and the purging aperture being "for blowing the N<sub>2</sub> gas into the space..." do not positively recite structure relating to the gas, such as being connected to an N<sub>2</sub> gas source. A recitation of the intended use of the claimed invention must result in a structural difference between the claimed invention and the prior art in order to patentably distinguish the claimed invention from the prior art. If the prior art structure is capable of performing the intended use, then it meets the claim. See *In re Casey*, 370 F.2d 576, 152 USPQ 235 (CCPA 1967) and *In re Otto*, 312 F.2d 937, 939, 136 USPQ 458, 459 (CCPA 1963). Recitation of YAMAGATA reads on applicant's claimed invention.

5. Claims 1 & 5 are rejected under 35 U.S.C. 102(b) as being anticipated by US 5,534,073 to KINOSHITA *et al.* (hereinafter "KINOSHITA"). Re claim 1, KINOSHITA discloses a wafer holding unit comprising an holder plate (101) and an outer peripheral vacuum suction member defined by two annular grooves (107) formed by at least two ring-shaped members, apertures (113/108) and the vacuum chuck device having a purging aperture ("holes of a vacuum chuck are provided corresponding to holes of a gas nozzle provided at a position making a pair with the vacuum chuck", see, for instance, col. 8, lines 47-51 of Kinoshita et al.) (see *also* Figures 11-18 and relative

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associated text). Re claim 5, KINOSHITA discloses a semiconductor processing (producing) device having the wafer chucking (holding) device and surface processing unit (CVD device), and cleaning (for instance, col. 1, lines 9-18).

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## Claim Rejections - 35 USC § 103

- 6. The text of those sections of Title 35, U.S. Code not included in this action can be found in a prior Office action.
- 7. Claims 6-8 are rejected under 35 U.S.C. 103(a) as being unpatentable over KINOSHITA in view of U.S. Patent No. 6,164,133 to WATANABE. Recitation of KINOSHITA is repeated here from above. Although KINOSHITA discloses a surface processing unit for CVD and cleaning, KINOSHITA does not expressly disclose a processing apparatus including a surface processing unit, an cleaning/drying unit, a dipping bath and an evaluation unit. WATANABE teaches that it is known to utilize a vacuum wafer holding unit as a part of a processing apparatus (30) with a surface processing unit (23), a dipping bath (24) in which the substrate is lowered by the holding unit "so that its entire surface is immersed into the collecting liquid", a cleaning unit (ultrasonic means (23') or heating means (23")) used for "removing contaminating matter and impurities by cleaning", and an evaluation unit (not shown) for "surface analysis" (see entire reference of WATANABE, for instance, Figure 1, col. 3, lines 26-35, col. 4, lines 14-33, and col. 7, lines 15-20). Therefore, the position is taken that a person of ordinary skill in the art at the time the invention was made would have been motivated to modify the processing apparatus including a vacuum wafer holding unit,

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disclosed by KINOSHITA, with the processing apparatus, disclosed by WATANABE, in order to provide improved, thorough processing and cleaning of a semiconductor.

### Conclusion

- 8. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Joseph L. Perrin, Ph.D. whose telephone number is (571)272-1305. The examiner can normally be reached on M-F 7:00-4:30, except alternate Fridays.
- 9. If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Michael E. Barr can be reached on (571)272-1414. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.
- 10. Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Joseph L. Perrin, Ph.D.

Examiner Art Unit 1746